

## INFORMATION DISCLOSURE STATEMENT BY APPLICANT

Application Number	Unknown 10/805,747
Filing Date	Herewith
Applicant(s)	Wu et al.
Art Unit	Unknown
Examiner Name	Unknown
Attorney Docket Number	24061.200 (TSMC2003-1585)

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OTHER PRIOR ART		
Examiners' Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article, title of the item, date, page(s), volume, issue, number(s), publisher, city/country where published
	AG	ALAVI, et al., A PROM Element Based on Salicide Agglomeration of Poly Fuses in a CMOS Logic Process, December 1997, 4 pgs., IEEE International Electron Device Meeting.
	AM	MICHAEL WU, Electrical Fuse Structure for Low Voltage and Single Core Applications, December 16, 2003, 4 pgs., Taiwan Semiconductor Manufacturing Company, Ltd.

Date  
Considered

9/05

→ AG and AH references not considered because they are not in the PTO file.